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Sheet 1 of 1

FORM 1449\*

INFORMATION DISCLOSURE STATEMENT

IN AN APPLICATION

(Use several sheets if necessary)

Docket Number: 14633.0006USWO / Booksalion Surset Unknown

Applicant: ITO et al.

Filing Date: January 14, 2005

Group Art Unit: Unknown

|                     |                       | <u> </u>  | U.S. PATENT DOCUMEN  | NTS                     |                   |                            |           |
|---------------------|-----------------------|---|--|-------------------------|-------------------|----------------------------|-----------|
| EXAMINER<br>INITIAL | DOCUMENT NO.          | DATE  | NAME   | CLASS                   | SUBCLASS          | FILING DATE IF APPROPRIATE |           |
|                     | 3,849,458             | 11/1974   | Dinh-Nguyen et al.   |                         |                   |                            | _         |
|                     |                       |   |  |                         |                   |                            |           |
|                     |                       |   |  |                         |                   |                            |           |
|                     |                       | FO  | REIGN PATENT DOCUM   | 1ENTS                   | 1                 | 1                          |           |
|                     | DOCUMENT NO.          | DATE  | COUNTRY  | CLASS                   | SUBCLASS          | TRANSLATION                |           |
|                     |                       |   |  |                         |                   | YES                        | NO        |
|                     | 47-12567              | 06/1972   | Japan  |                         |                   | Abstract                   |           |
|                     | 62-56441              | 03/1987   | Japan  |                         |                   | Abstract                   |           |
|                     | 63-30435              | 02/1988   | Japan  |                         |                   | Abstract                   |           |
|                     | 63-30450              | 02/1988   | Japan  |                         |                   | Abstract                   |           |
|                     | 63-198638             | 08/1988   | Japan  |                         |                   | Abstract                   |           |
|                     | 6-228014              | 08/1994   | Japan  |                         |                   | Abstract                   |           |
|                     | ОТНЕ                  | R DOCUMENT  | S (Including Author, Title,                                | Date, Pertinent I       | ages, Etc.)       |                            |           |
|                     | Baker et<br>Detritiat | al., "Aromatic R<br>ion", Chemical A  | eactivity. Part XX. Dipher<br>Abstracts (1961); 56: 5077-5 | yl Sulphide, Dib<br>081 | penzofuran, and D | ibenzothiophen             | ı in      |
|                     |                       |   | h Temperature and Dilute A<br>Peuterium. II", Canadian Jou |                         |                   |                            | Replacing |
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PATENT TRADEMARK OFFICE

EXAMINER /Chukwuma Nwaonicha/

DATE CONSIDERED

07/16/2008

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.